

## Supporting Information

### In-situ Growth of Binder-Free CoNi<sub>0.5</sub>-MOF/CC Electrode for High-Performance Flexible Solid-State Supercapacitor Application

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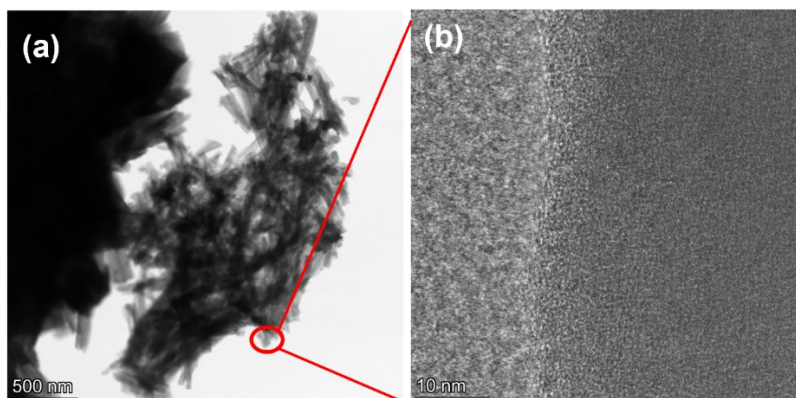


Figure S1 TEM image of CoNi<sub>0.5</sub>-MOF/CC with different magnification

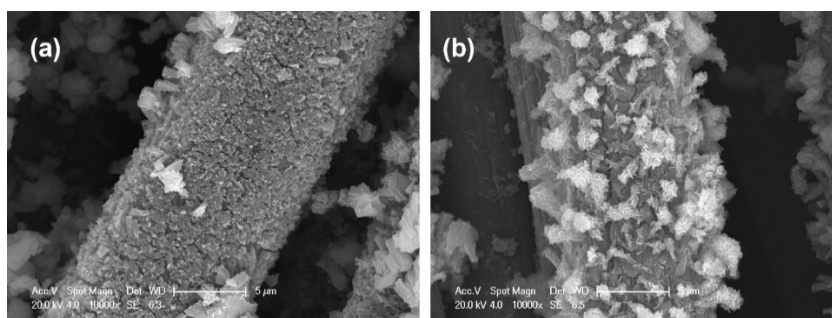


Figure S2 high resolution SEM image of CoNi<sub>0.5</sub>-MOF before and after 6000 cycles test

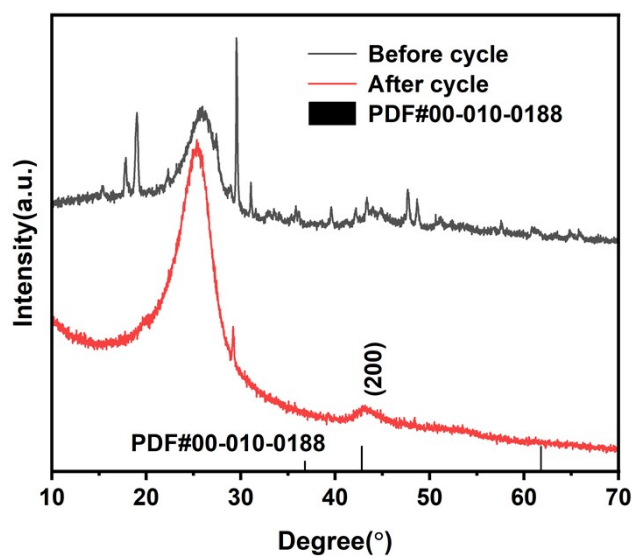
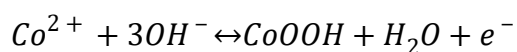
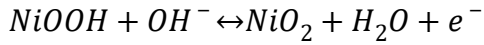
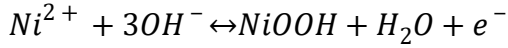
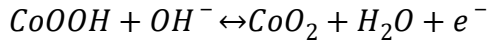


Figure S3 The XRD pattern of CoNi<sub>0.5</sub>-MOF/CC before and after cycle test

To evaluate the stability of the CoNi<sub>0.5</sub>-MOF structure during the electrochemical process, we fabricated electrodes and subjected them to 6000 cycles under a current density of 10 A g<sup>-1</sup>. Comparative analysis of the scanning electron microscopy (SEM) results indicates that while there were slight changes in the morphology of CoNi<sub>0.5</sub>-MOF due to expansion during the electrochemical process, the active material maintained good contact with the substrate without collapsing or detaching. This observation confirms the retention of cycle stability. Additionally, we examined the detailed structure of the electrode after cycling. Figure S3 illustrates that following electrochemical cycling, there were alterations in the lattice structure of CoNi<sub>0.5</sub>-MOF, with the disappearance of typical MOF peaks and the emergence of CoNiO<sub>2</sub> peaks. This transformation is likely attributed to the following electrochemical reactions occurring during cycling:





Electrode Material	Capacitor	Energy Density	Power Density	Reference
CoNi-MOF/AC	asymmetric	35 Wh kg <sup>-1</sup>	1450 W kg <sup>-1</sup>	2
Ni-MOF/AC	asymmetric	30.4 Wh kg <sup>-1</sup>	407.4 W kg <sup>-1</sup>	3
NiCo-LDH//AC	asymmetric	50.5 Wh kg <sup>-1</sup>	750 W kg <sup>-1</sup>	4
P-ZIF-67//AC	asymmetric	19.7 Wh kg <sup>-1</sup>	500 W kg <sup>-1</sup>	5
ZFO@NMO NSAs@rGO-NF// MDHPC	asymmetric	58.6 Wh kg <sup>-1</sup>	799 W kg <sup>-1</sup>	6
NiCo-MOF//(AC)	asymmetric	45.3 Wh kg <sup>-1</sup>	847.8 W kg <sup>-1</sup>	7
CoNi <sub>0.5</sub> -MOF/CC// N-Gr	asymmetric	61.46 Wh kg <sup>-1</sup>	1244.56 W kg <sup>-1</sup>	This work

Table.S1 Comparison of the performance of CoNi<sub>0.5</sub>-MOF /CC// N-Gr asymmetric supercapacitors with other supercapacitors

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